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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANT : Keun Deok Park
SERIAL NO. : 10/607,156 EXAMINER : Daniel S. Metzmaier
FILED : June 26, 2003 ART UNIT : 1712
FOR : COLLOIDAL SILICA COMPOSITION AND PRODUCTION METHOD
THEREOF

RESPONSE TO REQUIREMENT FOR RESTRICTION
UNDER 35 U.S.C. §121
And
PRELIMINARY AMENDMENT

MAIL STOP AMENDMENT
COMMISSIONER FOR PATENTS
P.O. BOX 1450
ALEXANDRIA, VA. 22313

Dear Sir:

Responsive to the Office Action dated June 23, 2005, issued in connection with the above-identified Application, which is now due for response on July 23, 2005, please consider the following remarks.